



PATENT
YOR920040022 IBM-272

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Matthew Colburn, et al.
Serial Number : 10/799,282
Filing Date : March 13, 2004
Examiner : To Be Determined
Group Art Unit : To Be Determined
For : Method for Fabricating Dual Damascene Structures
Using Photo-Imprint Lithography, Methods for
Fabricating Imprint Lithography Molds for Dual
Damascene Structures, Materials for Imprintable
Dielectrics and Equipment for Photo-Imprint
Lithography Used in Dual Damascene Patterning.

TO: The Honorable Commissioner of Patents
and Trademarks
Washington, D.C. 20231

Applicants enclose herewith an original copy of the fully signed declaration in this case.
The Commissioner is hereby authorized to charge Deposit Account 50-0510 the amount of
\$130.00 to cover the cost of the declaration surcharge. A duplicate copy of this page is
enclosed.

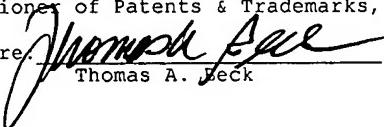
Respectfully Submitted,


Thomas A. Beck

Registration No. 20,816
26 Rockledge Lane
New Milford, CT 06776
Telephone (860) 354-0892

06/23/2004 EAREGAY1 00000033 500510 10799282
01 FC:1051 130.00 DA

I hereby certify that this paper is being transmitted by First Class mail addressed to
Commissioner of Patents & Trademarks, Post Office Box 1450, Alexandria, VA 22313-1450.

Signature: 
Name: Thomas A. Beck

Date: June 17, 2004